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FAX TRANSMISSION

DATE: Feb. 13th, 2009

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RE: Likelihood of being awarded the patent

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Dear Examiner Running,

For the past several years, I have been filing this application through a local Japanese patent office, who in turn have been going through a local U.S. patent office. But regarding the Office Action Summary mail dated 12/17/2008 (5703-000012/US/NP), instead of relying on the rather lack of a strong suggestion from the law office and due to my layperson's level of knowledge of the patent process, I would like to contact you directly to ask a few brief, basic questions concerning the likelihood of this application being granted a patent.

It is my understanding from the reading that, even if the Specifications are shortened, and the Drawings labelings as well as the informalities of Claim Objections 1,2,6, and 8 are corrected as you very kindly suggest, Claim Rejections 35 USC 102 and 103 note prior arts that would supposedly (from a layperson's view) make the patent application unpatentable.

Thus, is the chance of my being awarded this patent very low(almost none?) if ONLY, or EVEN IF, the labeling and informalities corrections are made? Is there a possibility of making a significant, convincing argument that the noted prior arts do not make my application so obvious or is it fairly close to final that they do make it unpatentable? Is there some way to make it worthwhile to continue the process in hopes of receiving a patent?

Since the local Japanese patent office wishes for my direction by coming Monday, I will try to call your office again on Monday if I don't receive a written response from your office in the meantime.

Lastly, please forgive me if I ask too basic a question and a sincere thanks for the tremendous work and feedback you all have given my application.

Very best regards,
Gene Huh.